

Xennia Emerald

who can differentiate your
brand with impactful and
sustainable color?

you can.

working for you.



Differentiate your brand with impactful and sustainable color

Print precise, intense color across a broad range of applications with Xennia Emerald, Sun Chemical's water-based digital pigment ink. Designed to raise the bar in color and print performance on cotton, cotton/polyester blends and other textile fibers, Xennia Emerald ink has been optimized for increased open time and latency resulting in simple use and minimal maintenance.

Uniquely applicable for both Epson and Kyocera printheads, Xennia Emerald allows you to achieve outstanding print detail and vibrant colors consistently over a range of different printers, so you can be confident in batch-to-batch uniformity, protecting your brand. By harnessing the latest in pigment-resin technology, color intensity is maximized and, as excellent print runnability is also standard with Xennia Emerald.

Key performance benefits

- Outstanding print runnability
- Strong application performance
- Easy installation and start-up
- Consistent color sharpness and vibrancy
- Excellent stability over long production runs
- Minimal maintenance and increased open time

Available colors



Applications for Xennia Emerald



Fashion apparel

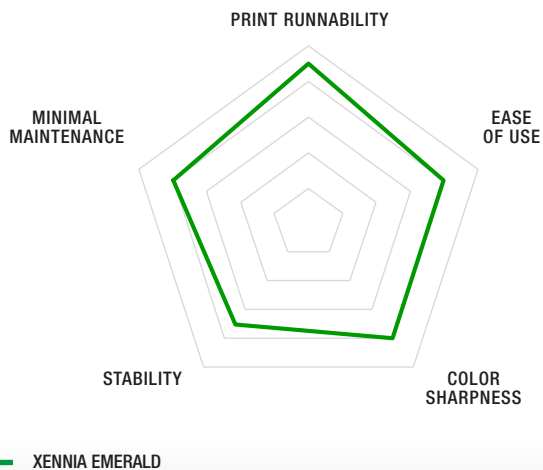


Interior Textiles

Innovation to set you apart

Xennia Emerald's innovating formulation enables significantly reduced maintenance and start-up delays. This enables a reduction of waste, adding to the significant sustainability benefits of pigment printing reducing water energy and emissions.

See it to believe it



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